

Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 14875-148US1	Application No. N/A
<b>Information Disclosure Statement by Applicant</b> (Use several sheets if necessary)  (37 CFR §1.98(b))		Applicant Tetsuo Kojima	
		Filing Date July 20, 2005	Group Art Unit

**U.S. Patent Documents**

Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						

**Foreign Patent Documents or Published Foreign Patent Applications**

Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation Yes      No
	AB						

**Other Documents (include Author, Title, Date, and Place of Publication)**

Examiner Initial	Desig. ID	Document
	AC	McGuinness BT et al., "Phage diabody repertoires for selection of large number of bispecific antibody fragments", Nature Biotechnology, Vol. 14(9), pages 1149-1154 (1996).
	AD	DeNardo D.G. et al., "Anti-HLA-DR/anti-DOTA diabody construction in modular gene design platform: bispecific antibodies for pretargeted radioimmunotherapy", Cancer Biotherapy & Radiopharmaceuticals, Vol. 16(6), pages 525-535 (2001).
	AE	Andris-Widhopf J. et al., "Methods for the generation of chicken monoclonal antibody fragments by phage display", Journal of Immunological Methods, Vol. 242, pages 159-181 (2000).
		Turner D.J. et al., "Importance of the linker in expression of single-chain Fv antibody fragments: optimization of peptide sequence using phage display technology", Journal of Immunological Methods, Vol. 205, pages 43-54 (1997).
	AF	Tang Y. et al., "Selection of linkers for a catalytic single-chain antibody using phage display technology", The Journal of Biological Chemistry, Vol. 271(20), pages 15082-15086 (1996).
	AG	Holliger P. et al., "Diabodies", small bivalent and bispecific antibody fragments", Proc. Natl. Acad. Sci. USA, Vol. 90, pages 6444-6448 (1993).
	AI	

Examiner Signature	Date Considered
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	